

Description	High current implanter
Tool ID	HIC10
Tool Serial Number	#390
OEM	SEN
Model	LEX
Vintage	2003
Process	High current ion implanter
Wafer Size	200MM
Wafer Shape	SNNF (Semi Notch No Flat)
Wafer Cassette	8" Plastic Miraial
SMIF Interface	NO
Power Distribution	200V 60Hz 70KVA 3phase
Software Version Number	L6.00G
Beam Energy	0.2-70keV
Gasbox1	Ar HP external supply
Gasbox2	BF3 HP
Gasbox3	PH3 SDS
Gasbox4	AsH3 SDS
Cryo pump	Daikin V208SC612FH
Cryo pump	Daikin V24MC608GSR
Cryo Compressor	Daikin U110DWCH
Roughing Pump	Ebara A07V
Roughing Pump	Ebara A30W
TMP	MITSUBISHI PT-1500
TMP	SEIKO SEIKI STP-H2002C
Seal pump	ALCATEL MDP5011
Seal pump	ULVAC DA-20D
Ion Source	ELS type Mo-ARC CHAMBER
Vaporizer	Nothing

photograph



